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# COLLOIDS AND SURFACES

AN INTERNATIONAL JOURNAL

A: PHYSICOCHEMICAL AND  
ENGINEERING ASPECTS

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Colloids and Surfaces  
A: Physicochemical and Engineering Aspects 137 (1998) 391–393

## Announcements

International Association of Colloid and Interface Scientists

From: Newsletter No. 27, June 1997

Compiled by J. Lyklema



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# COLLOIDS AND SURFACES

## A: PHYSICO-CHEMICAL AND ENGINEERING ASPECTS

AN INTERNATIONAL JOURNAL DEVOTED TO THE PRINCIPLES AND APPLICATIONS OF COLLOID AND INTERFACE SCIENCE

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### Scope of the Journal

*Colloids and Surfaces A: Physicochemical and Engineering Aspects* is an international journal devoted to the science of the fundamentals, engineering fundamentals, and applications of colloidal and interfacial phenomena and processes. The journal aims at publishing research papers of high quality and lasting value. In addition, the journal contains critical review papers by acclaimed experts, brief notes, letters, book reviews, and announcements.

Basic areas of interest include the following: theory and experiments on fluid interfaces; adsorption; surface aspects of catalysis; dispersion preparation, characterization and stability; aerosols, foams and emulsions; surface forces; micelles and microemulsions; light scattering and spectroscopy; detergency and wetting; thin films, liquid membranes and bilayers; surfactant science; polymer colloids; rheology of colloidal and disperse systems; electrical phenomena in interfacial and disperse systems. These and related areas are rich and broadly applicable to many industrial, biological and agricultural systems.

Of interest are applications of colloidal and interfacial phenomena in the following areas: separation processes; materials processing; biological systems (see also companion publication *Colloids and Surfaces B: Biointerfaces*); environmental and aquatic systems; minerals extraction and metallurgy; paper and pulp production; coal cleaning and processing; oil recovery; household products and cosmetics; pharmaceutical preparations; agricultural, soil and food engineering; chemical and mechanical engineering.

### Audience

Surface and Colloid Chemists, Separation Chemists, Powder Technologists, Mineral Processors, Petroleum Engineers, Environmental, Soap, Cosmetic and Textile Scientists, Biological and Bioengineers, Tribologists.

### Publication Schedule and Subscription Information

*Colloids and Surfaces A: Physicochemical and Engineering Aspects* (ISSN 0927-7757). For 1998 volumes 130-141 are scheduled for publication. Subscription prices are available upon request from the publisher. Subscriptions are accepted on a prepaid basis only and are entered on a calendar year basis. Issues are sent by surface mail except to the following countries where air delivery via SAL mail is ensured: Argentina, Australia, Brazil, Canada, Hong Kong, India, Israel, Japan, Malaysia, Mexico, New Zealand, Pakistan, PR China, Singapore, South Africa, South Korea, Taiwan, Thailand, USA. For all other countries airmail rates are available upon request. Claims for missing issues must be made within six months of our publication (mailing) date.



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AND  
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A

## Announcements

### International Association of Colloid and Interface Scientists

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**6th Wolfgang-Ostwald-Kolloquium - Horizonte 2000**, 4-6 June, Jülich, Germany. Organised by the German Kolloid-Gesellschaft in honour of the 60th birthday of Professor Milan J. Schwuger. Contact: G. Lagaly, Institut für anorganische Chemie der Universität Kiel, Olshausenstraße 40/60, D-24098 Kiel, Germany. Phone: +49 (431) 880-3261; Fax: +49 (431) 880-1520. Also W. von Rybinski, Henkel KGaA, TTR-Physical Chemistry, Henkelstraße 67, D-40191 Küsseldorf, Germany. Phone: +49 (211) 797-2984; Fax: +49 (211) 798-8953.

**12th International Symposium on Surfactants in Solution**, 7-11 June 1988, Stockholm, Sweden. Contact: Stockholm Convention Bureau SIS-98, P.O. Box 6911, SE-102 39 Stockholm, Sweden. Phone: +46 (8) 736-1500; Fax: +46 (8) 348-441; E-mail: stocon@stocon.postnet.se.

**3rd World Congress on Particle Technology**, 7-9 July 1998, Brighton, U.K. Incorporating the **3rd Biennial Particle Technology Forum of the AIChE**. Contact: J. Black, Conference Section IChemE, 165-189 Railway Terrace, Rugby CV21 3HQ, U.K. Phone: +44 (1788) 578-214; Fax: +44 (1788) 577-182; E-mail: Jblack@icheme.org.uk.

**37th International Symposium on Macromolecules MACRO'98**, 13-17 July 1998, Gold Coast, Queensland, Australia. Contact: MACRO'98 AUSTRALIA, Chemistry Department, The University of Queensland, Brisbane, Qld. 4072, Australia. Fax: +61 (7) 365-3628.

**18th Discussion Conference of Macromolecules: Mechanical Behaviour of Polymeric Materials**, 20-23 July 1998, Prague, Czech Republic. Contact: J. Lukás, Institute of Macromolecular Chemistry, Academy of Sciences of the Czech Republic, Heyrovského nám 2, 16206 Prague 6 Petřiny, Czech Republic.

**216th ACS National Meeting**, 23-27 August 1998, Boston, U.S.A. The symposia include the following a *Division of Colloid and Surface Chemistry*. Contact: D.D. Miller, Eastman Kodak Co., 1999 Lake Avenue, Rochester, NY 14650-2109, U.S.A. Phone: +1 (716) 588-8146; Fax: +1 (716) 722-2327; E-mail: ddmiller@kodak.com.

Apparent and Microscopic Contact Angles

Nonequilibrium Dynamic Processes at Colloidal Interfaces.

Electrochemical Surface Science: Electrochemistry at Nanostructures Materials.

Association Colloids as Living Polymers.

Characterization and Application of Colloid Systems. In honor of the retirement of Professor R.L. Rowell.

Contact Angle and Wetting Phenomena.

Microscopy Techniques Bio-Interfacial Science

Poster Session: Fundamentals of Colloid and Surface Chemistry.

**International Symposium on Silica: SILICA from S (Synthesis) to A (Application)**, 1–4 September 1998, Mulhouse, France. Contact: B. Haidar, Institut de Chimie des Surfaces et Interfaces CNRS, P.O. Box 2488, F-68057 Mulhouse Cedex, France. Phone: +33 (3) 8960-8806; Fax: +33 (3) 8960-8799; E-mail: B. Haidar@univ-mulhouse.fr.

**12th Conference of the European Colloid and Interface Society (ECIS98)**, 20–25 September 1998, Dubrovnik, Croatia. Contact: D. Tezak, Department of Chemistry, University of Zagreb, Marulicev Trg 29, HR-10001 Zagreb, Croatia.

**International Conference on Colloid Chemistry and Physical—Chemical Mechanics**, devoted to the centennial of P.A. Rebinder's birthday, October 1998, Moscow, Russia. Contact: A.V. Pertsov, Chemistry Faculty, Moscow State University, Moscow 119899, Russia. E-mail: Pertsov@rehb.chem.msu.su. Also A.I. Rusanov, University of St. Petersburg, Faculty of Chemistry, Sredni Prospekt 41/43, St. Petersburg B-4, Russia. Phone: +7 (812) 218-9733; Fax: +7 (812) 218-1346; E-mail: korn@org.chem.lgu.sp6.54.

**15th European Chemistry at Interfaces Conference**, 18–23 October 1998, Jerusalem, Israel. *Note change of dates.* Contact: S. Magdassi, The Hebrew University of Jerusalem, Casali Institute of Applied Chemistry, Givat Ram Campus, Jerusalem 91904, Israel. Phone: +972 (2) 6580-4967; Fax: +972 (2) 652-8250; E-mail: magdassi@cc.huji.ac.il.

**Thin Films and Foams**, 3 November 1998, London, U.K. Organised by the Society of Chemical Industry. Contact: J.H. Clint. E-mail: j.h.clint@chem.hull.ac.uk. Also T. Cosgrove, School of Chemistry, University of Bristol, Cantock's Close, Bristol BS18 1TS, U.K. Phone: +44 (117) 928-7663; Fax: +44 (117) 925-0612; E-mail: L.terence.cosgrove@bristol-ac-uk.

**Microcrystallisation and Colloidal Precipitation**, 20 November 1998, London, U.K. Organised by the Society of Chemical Industry. Contact: D.J. Wedlock. E-mail: d.j.wedlock@mssmail.sailtho.simis.com. Also T. Cosgrove, School of

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**Molecular Interactions of Biomembranes: A Discussion of the Physical Chemistry of Biomembrane Structure, Interactions and Processes** (General Discussion 111 of the Faraday Division of the Royal Society of Chemistry), 16–18 December 1998, Bristol, U.K. Contact: S. Riaz, The Royal Society of Chemistry, Burlington House, Piccadilly, London W1V 0BN, U.K. Phone: +44 (117) 9437-8656; Fax: +44 (117) 9734-1227; E-mail: Riazs@rsc.org.

#### Preview 1999 and later

**217th ACS National Meeting**, 21–25 March 1999, Anaheim, U.S.A. *Division of Colloid and Surface Chemistry.* Contact: D.D. Miller, Eastman Kodak Co., 1999 Lake Avenue, Rochester, NY 14650-2109, U.S.A. Phone: +1 (716) 588-8146; Fax: +1 (716) 722-2327; E-mail: ddmiller@kodak.com.

**73rd Colloid and Surface Science Symposium**, June 1999, University Park, Pennsylvania, PA, U.S.A. Contact: T. Hatton, Department of Chemical Engineering, Massachusetts Institute of Technology, Cambridge, MA 02139, U.S.A. Phone: +1 (617) 253-4588; E-mail: tahatton@MIT.EDU.

**218th ACS National Meeting**, August 1999, New Orleans, U.S.A. *Division of Colloid and Surface Chemistry.* Contact: D.D. Miller, Eastman Kodak Co., 1999 Lake Avenue, Rochester, NY 14650-2109, U.S.A. Phone: +1 (716) 588-8146; Fax: +1 (716) 722-2327; E-mail: ddmiller@kodak.com.

**39. Hauptversammlung der Kolloid-Gesellschaft** (with international participation), September–October 1999, Würzburg, Germany.

**74th Colloid and Surface Science Symposium**, 2000, Lehigh University, Bethlehem, Pennsylvania, PA, U.S.A.

**International Symposium on Macromolecules MACRO 2000**, 9-14 July 2000, Warsaw, Poland. Contact: S. Penczek, Centrum Badan Molekularnych i Makromolekularnych, Polskiej Akademii Nauk, ul. Sienkiewicza 112, PL-90363 Lodz, Poland. Phone: +48 (42) 8199-815; Fax: +48 (42) 847-126.

**10th International IACIS Conference on Surface and Colloid Science**, 23-29 July 2000, Bristol, U.K. Contact: T. Cosgrove, University of Bristol, School of Chemistry, Cantock's Close, Bristol BS8 1TS, U.K. Phone: +44 (117) 928-7663; Fax: +44 (117) 925-0612; E-mail: [terence.cosgrove@brist.ac.uk](mailto:terence.cosgrove@brist.ac.uk),

<http://www.tlchm.bris.ac.uk/IACIS/IACIShome.htm>.

**75th Colloid and Surface Science Symposium ACS**, 10-13 June 2001, Pittsburgh, Pennsylvania, PA, U.S.A. Contact: S. Garoff, Carnegie Mellon University, Department of Physics, Pittsburgh, PA 15213, U.S.A. Phone: +1 (412) 268-6877; Fax: +1 (412) 681-0648; E-mail: [sg2e@andrew.cmu.edu](mailto:sg2e@andrew.cmu.edu). Also R.D. Tilton, Carnegie Mellon University, Department of Chemical Engineering, Pittsburgh, PA 15213, U.S.A. Phone: +1 (412) 268-1159; Fax: +1 (412) 258-7139; E-mail: [tilton@andrew.cmu.edu](mailto:tilton@andrew.cmu.edu).

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